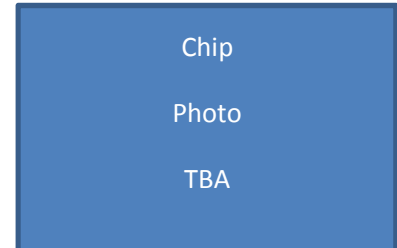


N-Channel Power Trench Mosfet Chip

FDP150N10A

100V, 50A, 15mΩ¹

| Part | V _{(BR)DSS} | I _{Dn} | R _{DS(on)} Max | Die Size |
|---|----------------------|-----------------|-------------------------|---------------------------|
| FDP150N10A | 100V | 50A | 15mΩ ¹ | 3.2 x 1.9 mm ² |
| See page 2 for ordering part numbers & supply formats | | | | |



Applications

- High density AC / DC Converters
- Motor drives & Micro Inverters

Features

- High Power & Current Handling Capability
- Low R_{DS (on)} per mm²
- Low Gate Charge, Fast Switching

Maximum Ratings

| Symbol | Parameter | Ratings | Units |
|-----------------------------------|---|---|-------|
| V _{DSS} | Drain to Source Voltage | 100 | V |
| V _{GSS} | Gate to Source Voltage | ±20 | V |
| I _D | Drain Current ² | Continuous (T _C = 25°C) | 50 |
| | | Continuous (T _C = 100°C) | 36 |
| I _{DM} | Drain Current ³ | Pulsed | 200 |
| T _J , T _{STG} | Operation Junction & Storage Temperature | -55 to 175 | °C |
| E _{AS} | Single Pulsed Avalanche Energy ⁴ | L = 2mH, I _{AS} = 9.2A, R _G =25Ω Starting T _J =25°C | 84.6 |
| dv/dt | Peak Diode Recovery dv/dt ⁴ | I _{SD} ≤100A, di/dt≤200A/μs, V _{DD} ≤BV _{DSS} Starting T _J =25°C | 6 |

Static Characteristics, T_J = 25° unless otherwise noted

| Symbol | Parameter | Test Conditions | Min | Typ | Max | Units |
|---------------------|---|---|-----|------|------|-------|
| BV _{DSS} | Drain to Source Breakdown Voltage | I _D = 250μA, V _{GS} = 0V | 100 | - | - | V |
| V _{GS(th)} | Gate threshold Voltage | V _{GS} = V _{DS} , I _D =250μA | 2.0 | - | 4.0 | V |
| I _{DSS} | Zero Gate Voltage Drain Current | V _{DS} = 80V, V _{GS} = 0V | - | - | 1 | μA |
| | Zero Gate Voltage Drain Current @ 150°C | V _{DS} = 80V, V _{GS} = 0V | - | - | 500 | |
| I _{GSS} | Gate to Body Leakage Current | V _{GS} = ±20V, V _{DS} = 0V | - | - | ±100 | nA |
| R _{DS(on)} | Static Drain to Source On Resistance ¹ | V _{GS} = 10V, I _D = 50A | - | 12.5 | 15.0 | mΩ |

Notes:

1. Defined by chip design, not subject to 100% production test at wafer level
2. Performance will vary based on assembly technique and substrate choice
3. Repetitive Rating: Pulse width limited by maximum junction temperature

Further Information - Contact your [Micross sales office](#) or email your enquiry to baredie@micross.com

Dynamic Characteristics⁴, T_j = 25°C unless otherwise noted

| Symbol | Parameter | Test Conditions | Min | Typ | Max | Units |
|---------------|------------------------------------|---|-----|------|------|----------|
| g_{FS} | Forward Transconductance | $V_{DS} = 10V, I_D = 50A$ | - | 40 | - | S |
| ESR | Equivalent Series Resistance (G-S) | $f = 1MHz$ | - | 1.3 | - | Ω |
| C_{iss} | Input Capacitance | $V_{DS} = 50V, V_{GS} = 0V$ $f = 1MHz$ | - | 1080 | 1440 | pF |
| C_{oss} | Output Capacitance | | - | 267 | 355 | pF |
| C_{rss} | Reverse Transfer Capacitance | | - | 11 | - | pF |
| $C_{oss(er)}$ | Energy Related Output Capacitance | $V_{DS} = 50V, V_{GS} = 0V$ | - | 436 | - | pF |
| $Q_{g(tot)}$ | Total Gate Charge at 10V | $V_{DS} = 50V, I_D = 50A$ $V_{GS} = 10V^5$ | - | 16.2 | 21.0 | nC |
| Q_{gs} | Gate to Source Gate Charge | | - | 5.3 | - | nC |
| Q_{gs2} | Gate Charge Threshold to Plateau | | - | 2.6 | - | nC |
| Q_{gd} | Gate to Drain "Miller" Charge | | - | 3.7 | - | nC |

Switching Characteristics⁴, T_j = 25°C unless otherwise noted

| Symbol | Parameter | Test Conditions | Min | Typ | Max | Units |
|--------------|---------------------|--|-----|-----|-----|-------|
| $t_{d(on)}$ | Turn-On Delay Time | $V_{DD} = 50V, I_D = 50A$ $V_{GS} = 10V, R_{GEN} = 4.7\Omega^5$ | - | 13 | 36 | ns |
| t_r | Turn-On Rise Time | | - | 16 | 42 | ns |
| $t_{d(off)}$ | Turn-Off Delay Time | | - | 21 | 52 | ns |
| t_f | Turn-Off Fall Time | | - | 5 | 20 | ns |

Drain-Source Diode Characteristics⁴, T_j = 25°C unless otherwise noted

| Symbol | Parameter | Test Conditions | Min | Typ | Max | Units |
|----------|--|---|-----|-----|-----|-------|
| I_S | Maximum Continuous Drain to Source Diode Forward Current | | - | - | 50 | A |
| I_{SM} | Maximum Pulsed Drain to Source Diode Forward Current | | - | - | 200 | A |
| V_{SD} | Drain to Source Diode Forward Voltage | $V_{GS} = 0V, I_{SD} = 50A$ | - | - | 1.3 | V |
| t_{rr} | Reverse Recovery Time | $V_{GS} = 0V, V_{DD} = 50V, I_{SD} = 50A$ $di_F/dt = 100A/\mu s$ | - | 50 | - | ns |
| Q_{rr} | Reverse Recovery Charge | | - | 55 | - | nC |

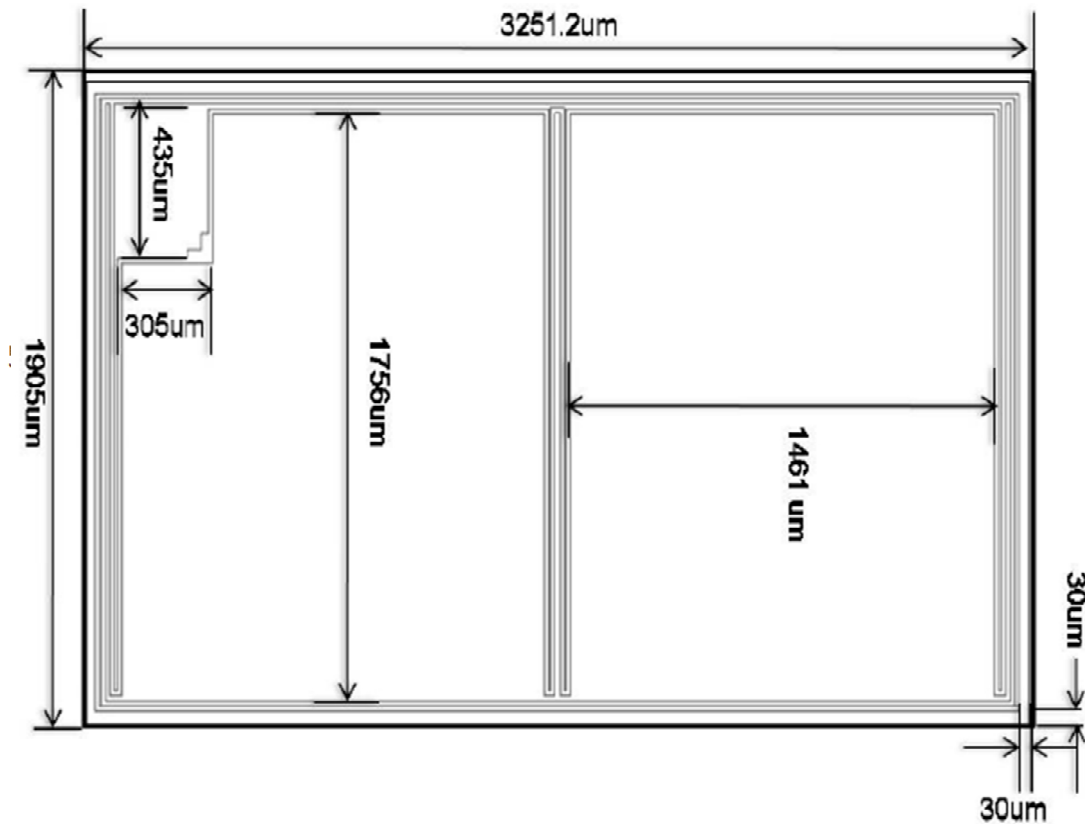
Notes:

- Characterised by design & tested at component level, not subject to production test at wafer level
- Essentially independent of Operating Temperature Typical Characteristics

Ordering Guide

| Part Number | Format | Detail / Drawing |
|--|---|------------------|
| FDP150N10AMW | Un-sawn wafer, electrical rejects inked | Page 3 |
| FDP150N10AMWF | Sawn wafer on film-frame | Page 4 |
| FDP150N10AMD | Singulated die / chips in waffle pack | Page 4 |
| Note: Singulated Die / Chips can also be supplied in Pocket Tape or SurfTape® on request | | |

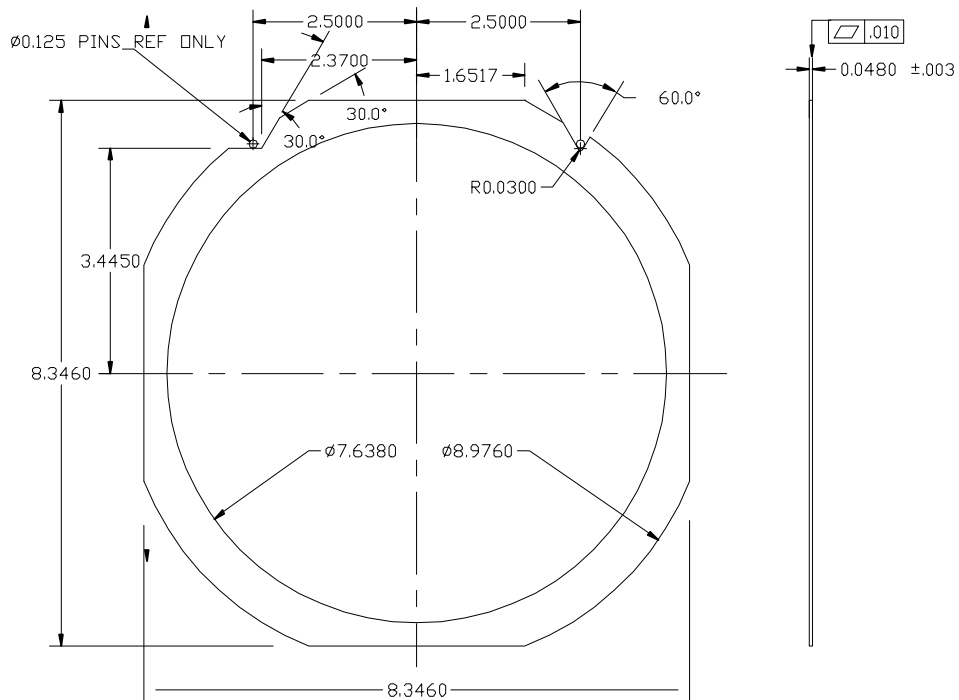
Die Drawing



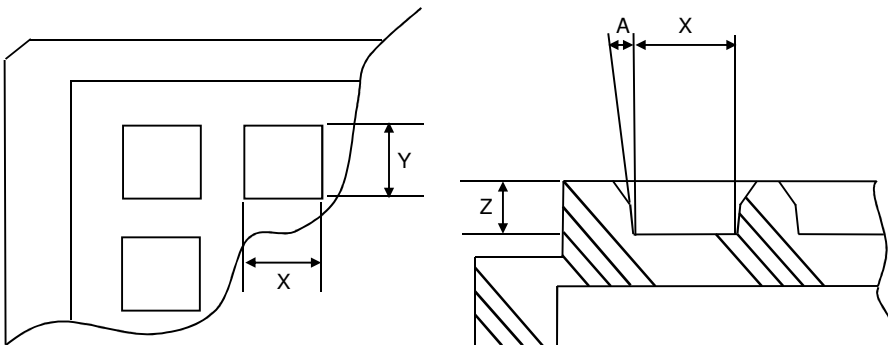
Mechanical Data

| Parameter | | Units |
|------------------------------------|--------------------------------------|---------|
| Chip Dimensions Un-sawn | 3251 x 1905 | μm |
| Chip Thickness (Nominal) | 200 | μm |
| Gate Pad Size | 305 x 435 | μm |
| Wafer Diameter | 200 (subject to change) | mm |
| Saw Street | 80 (subject to change) | μm |
| Wafer orientation on frame | Wafer notch parallel with frame flat | |
| Topside Metallisation & Thickness | Al / Cu +TiW+Ti | 4 μm |
| Backside Metallisation & Thickness | Ti-VNi-Ag | 0.65 μm |
| Topside Passivation | Unpassivated | |
| Recommended Die Attach Material | Soft Solder or Conductive Epoxy | |
| Recommended Wire Bond - Gate | Al 125μm X1 | |
| Recommended Wire Bond – Source | Al 500μm X2 | |

Sawn Wafer on Film-Frame – Dimensions (inches)



Die in Waffle Pack – Dimensions (mm)



X = 2.29mm ±0.13mm pocket size
 Y = 3.30mm ±0.13mm pocket size
 Z = 0.51mm ±0.08mm pocket depth
 A = 5° ±1/2° pocket draft angle
 No Cross Slots
 Array = 13 X 10 (12)

OVERALL TRAY SIZE

Size = 50.67mm ±0.25mm
 Height = 3.94mm ±0.13mm
 Flatness = 0.30mm

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